AMENDMENT TO CLAIMS [Deleted material is struck-through and added material is underlined]

1. - 5. (Cancelled)

6. (Currently Amended) An epoxy resin composition comprising: an epoxy resin prior to curing,

a non-clathrated curing agent reacting with an epoxy group of the epoxy resin to cure the resin, and

a tetrakisphenol compound represented by a general formula (I) as a curing accelerator catalyst,

$$R1$$
 $R3$
 CH
 $R4$
 $R5$
 $R6$
 $R8$
 $R7$
 $R8$

wherein X represents $(CH_2)n$, wherein n is 0, 1, 2 or 3, and R^1 to R^8 each represents hydrogen, a lower alkyl, a phenyl optionally substituted with halogen or C_1 - C_6 alkyl, a halogen or a C_1 - C_6 alkoxy.

wherein mono-substituted dicyandiamides is not used as an additive component,
and

wherein the content of said tetrakisphenol compound represented in formula (I) is a range from 0.001 to 0.1 mole based on 1 mole of the epoxy group.

7. (Canceled)

8. (Currently Amended) A method for curing an epoxy resin comprising a step of mixing a non-clathrated curing agent reacting with an epoxy group of the epoxy resin to cure the resin and a tetrakisphenol compound represented by a general formula (I) as a curing accelerator catalyst

with a non-curing epoxy resin,

$$R1$$
 $R3$
 C
 $R4$
 $R5$
 $R6$
 $R8$
 $R7$
 $R8$
 $R7$
 $R6$
 $R8$

wherein X represents (CH₂)n, wherein n is 0, 1, 2 or 3, and R^1 to R^8 each represents hydrogen, a lower alkyl, a phenyl optionally substituted with halogen or C_1 - C_6 alkyl, a halogen or a C_1 - C_6 alkoxy.

wherein mono-substituted dicyandiamides is not used as an additive component, and

wherein the content of said tetrakisphenol compound represented in formula (I) is a range from 0.001 to 0.1 mole based on 1 mole of the epoxy group..

9. (Canceled)

10. (Withdrawn) A curative for epoxy resin, comprising a clathrate comprising:

a tetrakisphenol compound represented by a general formula (I) and a compound reacting with an epoxy group to cure an epoxy resin,

$$R1$$
 $R3$
 CH
 $R2$
 $R4$
 $R5$
 $R6$
 $R8$
 $R7$
 CH
 $R6$
 $R8$
 $R8$

wherein X represents (CH₂)n, wherein n is 0, 1, 2 or 3, and R^1 to R^8 each represents hydrogen, a lower alkyl, a phenyl optionally substituted with halogen or C_1 - C_6 alkyl, a halogen or a C_1 - C_6 alkoxy.

11. (Withdrawn) A curing accelerator for epoxy resin, comprising a clathrate comprising a tetrakisphenol compound represented by a general formula (I) and a compound accelerating the curing of a compound reacting with an epoxy group to cure an epoxy resin,

wherein X represents $(CH_2)n$, wherein n is 0, 1, 2 or 3, and R^1 to R^8 each represents hydrogen, a lower alkyl, a phenyl optionally substituted with halogen or C_1 - C_6 alkyl, a halogen or a C_1 - C_6 alkoxy.

12. (Withdrawn) An epoxy resin composition comprising a non-curing epoxy resin, and a clathrate comprising a tetrakisphenol compound represented by a general formula (I) and a compound reacting with an epoxy group of the epoxy resin to cure the resin; and

a clathrate comprising a tetrakisphenol compound represented by a general formula (I) and a compound accelerating the curing of a compound reacting with an epoxy group to cure an epoxy resin,

$$R1$$
 $R3$
 CH
 $R2$
 $R4$
 $R5$
 $R7$
 $R6$
 $R8$
 $R8$
 $R7$

wherein X represents $(CH_2)n$, wherein n is 0, 1, 2 or 3, and R^1 to R^8 each represents hydrogen, a lower alkyl, a phenyl optionally substituted with halogen or C_1 - C_6 alkyl, a halogen or a C_1 - C_6 alkoxy.

- 13. (Withdrawn) The epoxy resin composition according to claim 11, wherein the content of a tetrakisphenol compound represented by a general formula (I) in the clathrate is in a range of from 0.001 to 0.1 mole based on 1 mole of the epoxy group.
- 14. (Withdrawn) The epoxy resin composition according to claim 12, wherein the content of a tetrakisphenol compound represented by a general formula (I) in the clathrate is in a range of from 0.001 to 0.1 mole based on 1 mole of the epoxy group.
- 15. (Withdrawn) A method for curing an epoxy resin composition comprising the steps of:

a clathrate comprising a tetrakisphenol compound represented by a general formula (I) and a compound reacting with an epoxy group of the epoxy resin to cure the resin is added and mixed to a non-curing epoxy resin, and then the mixture is heated to a predetermined temperature,

R1 R3

$$R2$$
 $R4$
 $R5$
 $R6$
 $R8$
 $R7$
 $R6$
 $R8$
 $R7$
 $R8$

wherein X represents $(CH_2)n$, wherein n is 0, 1, 2 or 3, and R^1 to R^8 each represents hydrogen, a lower alkyl, a phenyl optionally substituted with halogen or C_1 - C_6 alkyl, a halogen or a C_1 - C_6 alkoxy.

16. (Withdrawn) A method for curing an epoxy resin composition comprising the steps of:

a clathrate comprising a tetrakisphenol compound represented by a general formula (I) and a compound reacting with an epoxy group of the epoxy resin to cure the resin, and a clathrate comprising a tetrakisphenol compound represented by a general formula (I) and a compound accelerating the curing of a compound reacting with an epoxy group to cure an epoxy resin are added and mixed to a non-curing epoxy resin, and then the mixture is heated to a predetermined temperature,

wherein X represents $(CH_2)n$, wherein n is 0, 1, 2 or 3, and R^1 to R^8 each represents hydrogen, a lower alkyl, a phenyl optionally substituted with halogen or C_1 - C_6 alkyl, a halogen or a C_1 - C_6 alkoxy.

17. (Withdrawn) The method for curing an epoxy resin composition according to claim 15, wherein the content of the tetrakisphenol compound represented by a general formula (I) in the clathrate is in a range of from 0.001 to 0.1 mole based on 1 mole of the epoxy group.

18. (Withdrawn) The method for curing an epoxy resin composition according to claim 16, wherein the content of the tetrakisphenol compound represented by a general formula (I) in the clathrate is in a range of from 0.001 to 0.1 mole based on 1 mole of the epoxy group.